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Band-Gap Tunability in Partially Amorphous Silicon Nanoparticles Using Single-Dot Correlative Microscopy

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ABSTRACT: Silicon nanoparticles (Si-NPs) represent one of many types of nanomaterials, where the origin of emission is difficult to assess due to a complex interplay between the core and surface chemistry. Band-gap tunability in Si-NPs is predicted to span from the infrared to the ultraviolet spectral range, which is rarely observed in practice. In this work, we directly assess the size dependence of the optical band gap using a single-dot correlative microscopy tool, where the size of the individual NPs is measured using atomic force microscopy (AFM) and the optical band gap is evaluated from single-dot photoluminescence measured on the very same NPs. We analyze 2−8 nm alkyl-capped Si-NPs prepared by a sol−gel method, followed by annealing at 1300 °C. Surprisingly, we find that the optical band gap is given by the amorphous shell, as evidenced by the convergence of the optical band gap size dependence toward the amorphous Si band gap of ~1.56 eV. We propose that the structural disorder might be the reason behind the often reported limited emission tunability from various Si-NPs in the literature. We believe that our message points toward a pressing need for development and broader use of such direct correlative single-dot microscopy methods to avoid possible misinterpretations that could arise from attempts to recover size−band gap relation from ensemble methods, as practiced nowadays.

KEYWORDS: single-dot spectroscopy, correlative microscopy, silicon nanoparticles, size-tunability, amorphous silicon, quantum confinement

INTRODUCTION

Silicon (Si), an abundant and nontoxic material, is one of the most important semiconductors used nowadays. However, its indirect band gap renders its emission poor, which hampers its use in optoelectronic and photonic devices, such as light-emitting diodes or lasers. Also, its band-edge absorption is very inefficient, inhibiting the use of Si in thin-cell photovoltaics.

This is partially improved in small Si nanoparticles (Si-NPs) via quantum confinement effect (QCE) and surface engineering.1−3 Similar to other NPs, Si-NPs with a radius smaller than the excitonic Bohr radius have size-tunable band-gap energy.4−9 According to the effective mass approximation (EMA), the band-gap energy of a spherical crystalline NP deviates from its bulk value in inverse proportion to the square of the NP’s radius (the localization term) plus the term that scales inverse with the radius (polarization term),10 and a similar trend is also predicted by the first-principles methods.11,12 Theoretical predictions show that the emission tunability range of the Si-NPs should be one of the broadest among all of the semiconductors, spanning from the near-infrared (NIR) spectral range at 1.1 eV to the ultraviolet (UV) range at over 3.5 eV.2,6,8,9 In practice, however, weaker and/or limited size dependencies are observed.1,9 Such deviations from the predicted trend are often discussed in terms of the presence of extrinsic radiative channels, such as localized surface states or as a result of strain.13−15

In this work, we employ a direct experimental method for assessing the size dependence of the band-gap energy by a custom-built single-dot correlative microscopy tool combining optical single-dot microspectroscopy with atomic force microscopy (AFM). We use this tool to analyze the origin of emission from sol−gel-synthesized alkyl-capped Si-NPs. Such a material was earlier reported to consist of a crystalline Si core and an amorphous Si shell, despite annealing at 1300 °C, as evidenced by a detailed nuclear magnetic resonance (NMR) study.16 In their follow-up study, the authors concluded that the optical properties are dictated by the crystalline core,17

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based on an indirect, ensemble optical properties and X-ray diffraction (XRD) size analysis. We do confirm that such a material is partially amorphous, but using our direct size—band gap measurement, we find that the band gap for larger Si-NPs converges to 1.59 eV, which is the bulk band gap of amorphous Si. Our result shows that ensemble analysis can be misleading and that there is a critical need for such direct correlative measurements to be implemented in assessment of emission origin, especially for complex materials such as Si-NPs. Also, we suggest that disorder might be another often-neglected reason for the observed limited size-tunability in Si-NPs and similar materials.

RESULTS AND DISCUSSION
The structure and synthesis of the Si-NPs analyzed in this work are schematically summarized in Figure 1. Si-NPs were prepared by the group of Veinot by a sol–gel type of bottom-up synthesis, as described elsewhere. To improve the material quality, such Si-NPs were annealed at a high temperature of 1300 °C in forming H₂/N₂ gas and etched by hydrogen fluoride (HF) to remove any remaining Si oxide. The resulting material was capped by long alkyl chains (1-dodecene) and dispersed in toluene. The remaining surface bonds are likely oxidized, which, however, does not influence the colloidal stability of the Si-NPs in toluene. For more details, see the Methods section. Prior to the measurements, Si-NPs were stored for several years in toluene in dark ambient conditions in sealed vials. For comparison, we show ensemble photoluminescence (PL) spectra measured from a freshly prepared sample in Figure S8.

The ensemble structural and optical properties were characterized first. The mean size of the Si-NPs was measured using scanning transmission electron microscopy (STEM) to be 6.9 ± 1.6 nm (Figure S10). The ensemble optical properties, such as extinction, PL excitation (PLE), and PL spectra are shown in Figure S1. The extinction spectrum can be interpreted as an absorption spectrum, due to negligible scattering, evidenced by the almost exact match between the PLE and extinction spectra. This is in agreement with the observed lack of aggregation over several years of storage of the Si-NPs in toluene in the dark. The absorption spectrum is featureless, as expected for an indirect band-gap semiconductor material, with no prominent band-gap edge. To evaluate the band-gap edge, we plot absorption spectra in the Tauc plot for the indirect allowed transition (Figure S2), which reveals an optical band gap of 2.21 ± 0.01 eV. Steady-state PL spectra excited at three different wavelengths by a low-power continuous-wave (cw) laser peak close to 813 nm (inset in Figure S1). The full PLE map reveals only a negligible spectral shift of ~20 meV of the PL peak with the excitation wavelength (Figure S3), in agreement with the indirect band-gap character of the material and the resulting large Stokes shift between the excitation and emission energies. PL quantum yield (QY) was measured on this sample previously and found to be above 40%. This is a very high value for such Si-NPs, making them good a material for the demonstration of correlatable single-dot spectroscopy here. Similarly, high QY values for this type of material have also been previously reported by other groups.

Due to the size-effect, every single Si-NP has a different band gap and a radiative rate. In such a case, the ensemble optical analysis offers only a summed-up PL spectrum, whose peak does not directly translate into the mean Si-NP size. The emission rate of the single Si-NP depends strongly on its size, owing to the size-dependent radiative rate. Hence, the smaller Si-NPs are much brighter and contribute more to the ensemble PL than the larger Si-NPs. This means that the mean PL peak does not coincide with the mean Si-NP size but is blue-shifted. Furthermore, defect states (e.g., from silica oxide) can become stabilized inside the band gap in the smaller Si-NPs (and not the larger ones), owing to the band-gap opening. At the same time, smaller Si-NPs might be more prone to disorder and sensitive to the environment. Hence, the size dependence of the optical band gap of NPs cannot be inferred from the ensemble optical properties and requires an-depth single-NP PL spectroscopy, correlated with a size analysis of the same NPs. This can be done using, for example, our setup, described in Figure 2a (more details can be found in the Methods section), which allows us to directly measure and correlate for each single Si-NP its size, obtained from the AFM scan of the surface topography and measured with sub-nanometer resolution, with its optical band gap, obtained from the analysis of the single Si-NP PL spectrum. The procedure is sketched in Figure 2b–e. First, a PL image of a large 25 × 25 μm² area (=field of view (FOV)) is visualized by an optical microscope (Figure 2b) to identify the “anchoring” emissive nano-objects, such as the single Si-NPs or their clusters. This initial PL imaging is done very briefly (with an acquisition time of 8 s) to avoid photobleaching prior to the spectral analysis. The same area is consequently slowly scanned by an atomic force microscope in a tapping mode (Figure 2b) and the two images are correlated using the large anchors (encircled in Figure 2b,c). The tapping mode is used to avoid strong tip–sample interactions that could lead to displacement or removal of the Si-NPs during scanning. Afterward, the whole area is rescanned with a narrow slit placed in the image plane, using a longer acquisition time of 6 min for each spectrum. This allows us to capture PL spectra of all of the nano-objects in the scanned area and also those invisible to the initial PL image scan used for correlative purposes only. In Figure 2d,e, an example of a PL spectrum and size obtained from a Si-NP that...
Figure 2. (a) Schematic of the correlative microscope setup comprising an inverted optical microscope and an atomic force microscope. The microscope is coupled via a beam splitter to an avalanche photodiode (APD) and connected to a photon-correlating card and a spectrometer with a CCD detector cooled by liquid nitrogen (LN). (b) An example of an AFM scan image of the sparsely deposited Si-NPs on a high-quality quartz substrate. The scale bar is 5 μm. (c) PL microscopy image of the same area as in (b), acquired by the CCD detector. The PL image shown is a cutout of the whole field of view (FOV), which is 25 × 25 μm². The anchoring Si-NPs used for correlation purposes are encircled using yellow dashed circles. The whole scanned area is resampled with a narrow horizontal slit in the image plane and longer acquisition times to capture the single Si-NP PL spectra. This often reveals small Si-NPs that were invisible in the initial PL scan. This is also the case of a Si-NP indicated by an arrow in (b) and (c), whose PL spectrum and size are shown in (e) and (d), respectively.

Figure 3. (a) Plot of the optical band gaps for the likely single Si-NPs (blue spheres) obtained from fitting the PL peak of 50 single Si-NPs spectra as a function of the Si-NPs size evaluated from the AFM measurements. The vertical “error bars” are given as the FWHM of the single-dot PL spectra when fitted by a single Gaussian peak. The horizontal “error bar” is given by the average substrate roughness, which is a good estimate for the uncertainty in the measured single Si-NP height. Experimental data from this study (blue spheres) are compared with the literature: theoretical simulations of crystalline Si-NP by Wang et al.27 (green inverted triangle) and by Delerue et al.28 (purple inverted triangle) and experimental results on crystalline Si-NPs in SiO₂ matrix prepared by Takeoka et al.29 (black triangle), crystalline Si-NPs by Ledoux et al.30 (orange diamond), crystalline Si-NPs in Si₃N₄ matrix by Kim et al.31 (gray star), and amorphous Si-NPs in Si₃N₄ matrix by Park et al.32 (red square). Thick semitransparent lines are EMA model fits using fitting parameters reported by Wang et al.27 (green inverted triangle), Park et al.32 (red square), and Kim et al.31 (gray star). The blue line represents our own fit using the EMA model. (b) Histogram of the single Si-NP sizes, as obtained from the AFM topography scans, indicates a broad size distribution with a mean size of 4.4 ± 1.3 nm. (c) Ensemble PL spectrum (red line) compared with the sum of the 50 selected single-dot PL spectra (blue line), both measured in the same microscopy setup here with excitation by a 445 nm diode laser in the cw regime. PL peaks from the sum of single Si-NPs and ensemble are at 1.82 and 1.53 eV, respectively.
was initially not visible (VIS) on the brief PL scan (position is indicated by the arrow in Figure 2b,c) is shown. PL spectra of all of the Si-NPs within the scanned area are recorded without any selectivity by the spectrometer and a charge-coupled device (CCD), fitted and matched with the height information from the AFM scan, using the “anchoring” clusters. In this way, we obtain a direct measurement of the size dependence of the optical band gap of the Si-NPs. Since the lateral resolution of the atomic force microscope is limited by the size of the tip (usually larger than 10 nm), it is very difficult to prove that there is only a single Si-NP without including additional measurements, such as antibunching. We note that this is technically possible in our setup but was not used for these Si-NPs because of their slow PL lifetime. Hence, to make sure that our data are likely from single Si-NPs, we include for the final analysis of the size—band gap relation only the PL spectra with the narrowest full width at half-maximum (FWHM) and the lowest PL intensity within the respective spectral range, with the assumption that aggregates of multiple emissive Si-NPs of similar sizes effectively multiply the integral PL signal.

Our main results are summarized in Figure 3 that shows (a) an overview of the optical band gaps as a function of the NP size for all of the 50 measured likely single emitting Si-NPs (blue circles). Optical band gaps are approximated as the peak of each single-NP PL spectrum when fitted to an energy scale by a single Gaussian peak function (Figure S4) to reflect the fact that the measured PL spectrum originates from multiple transitions over time from a variety of states that are populated at room temperature (as opposed to a single transition that would lead to a Lorentzian shape). The PL spectra might consist of phonon-related replicas and be influenced by spectral diffusion, but given the noisy PL signal, this is hard to define. Nevertheless, we expect that a possible phonon structure and/or spectral diffusion can introduce error in the band-gap evaluation by only less than 100 meV, which does not influence critically the main size—band gap tunability result. A histogram of the fitted FWHMs of all of the evaluated single-NP PL spectra is plotted in Figure S5, revealing a broad mean FWHM of 200 meV, which is in excellent agreement with earlier independent measurements of a similar material by another group.

Sizes of the respective Si-NPs are retrieved from the topography profile measured by the atomic force microscope in tapping mode. The resolution of this analysis is a sub-nanometer for the height, limited by the mean roughness of the substrate, which is found to be below 0.3 nm (Figure S9). This is true only for the fresh high-quality quartz substrates, whose surface is found to generally become rougher with usage and repeated cleaning. The histogram of the Si-NP sizes obtained by AFM is shown in Figure 3b and gives a mean size of 4.4 ± 1.3 nm for the optically analyzed Si-NPs.

According to the effective mass approximation (EMA) model, the dependence of the optical band gap $E_g(R)$ on the radius of the NP $R$ can be fitted by the Brus equation:

$$E_g(R) ≈ E_g(∞) + \frac{\hbar^2}{2R^2} \left( \frac{1}{m_e} + \frac{1}{m_h} \right) - \frac{1.8e^2}{\epsilon R}$$  

where $E_g(∞)$ is the band-gap energy of the bulk material at room temperature, $h$ is reduced Planck constant, $m_e$ and $m_h$ are the effective masses of the electron and hole quasi-particles, respectively, and $\epsilon$ is the permittivity. The localization $1/R^2$ term for NPs in a strong confinement regime is much larger than the Coulombic $1/R$ term. For example, in a 1 nm Si-NP, the Coulombic term is only about 120 meV, while the localization term reaches few electronvolts. Therefore, it is usually considered that $E_g(R) \propto 1/R^2$, where $1 < x < 2$. Data by Park et al., Kim et al., and Wang et al. are fitted by EMA model parameters described in their respective studies with the results shown in Figure 3a in red, gray, and green thick semitransparent lines, respectively. Comparing our measured size dependence of the optical band gap in Figure 3a, we find a clear mismatch with all of the size dependencies theoretically simulated or experimentally measured for crystalline Si-NPs, especially for the larger Si-NP sizes. Instead, our result follows data reported experimentally for the amorphous Si-NPs by Park et al., fitted with a fixed $k^2/2m^* = 2.39$, a bulk band gap of 1.56 eV, and a power coefficient of $x ∼ 1.72$ (blue line in Figure 3a), characteristic for a bulk amorphous Si. Hence, our results strongly suggest that the analyzed Si-NPs are either fully amorphous or that the PL is dominated by the amorphous part of the Si-NP. This is a very interesting result, especially considering a recent study on a similar material system that suggests that it is the crystalline part that dominates the PL.

To characterize the crystallinity of our material, we performed X-ray diffraction (XRD) on the ensemble of Si-NPs and Raman microspectroscopy on a cluster of emissive Si-NPs (Figure 4). The XRD spectrum exhibits a characteristic diamond structure of crystalline Si with signals from characteristic (111), (220), (311), (400), (331), and (422) planes, confirming the presence of a crystalline Si phase in the Si-NP
structure. The signal is compared to a reference bulk crystalline Si material and an empty sample holder. The broad signature of the background results from the amorphous Si (see also Figure S12 for the sample XRD with the subtracted background), as it closely follows the signal detected from the sample holder (gray line).

The Raman spectra of several brightly emissive Si-NP clusters were measured using a Raman microscopy system (Figure 4b and for the other two clusters, Figure S11). The Raman signal shows two main components: (i) a strong narrow component (green) at 522.7 cm\(^{-1}\) and a broad peak at around 486 cm\(^{-1}\). The first peak corresponds to the well-documented nanocrystalline Si\(^{36-38}\) which is strongly red-shifted with respect to the bulk crystalline Si signal at 521 cm\(^{-1}\). The broader signal at 486 cm\(^{-1}\) corresponds to amorphous Si\(^{37,38}\) confirming the presence of both crystalline and amorphous phases within the Si-NPs. We also confirm that the sample is oxide-free, since we observe no features related to silica oxide\(^{39,40}\) in any of the Raman spectra. The presence of Si–O bonds on the Si-NP surface in small quantities is expected, due to the fact that surface coverage by organic ligands can only be partial due to steric hindrance. Nevertheless, the excellent colloidal stability of these Si-NPs in toluene and hexane indicates that the majority of the surface is organically coated. In summary, the Si-NPs are not fully oxidized nor fully amorphous but contain both amorphous and crystalline phases, likely in a form of a core–shell system, as suggested in the study by Veinot et al.\(^{15}\) Therefore, our results showing the convergence of the size-dependent band gap toward the bulk amorphous Si band gap of 1.59 eV in Figure 3a suggests that it is the amorphous phase that dictates the optical properties. We note here that besides the indication of crystallinity, XRD and Raman spectra can also be used to obtain an estimate of the NP mean size (see Supporting Information); however, such an evaluation is not without a considerable error of evaluation of the size of a crystalline core–amorphous shell system.

Further support for a strong involvement of the disordered phase in the PL process is provided by the fact that the single-NP PL spectral widths, quantified by the FWHM evaluated from the fitting by a Gaussian function (Figure S4), are very broad, about 200 meV in average (Figure S5). A high amount of disorder leads to the broadening of the phonon spectra, which in turn broadens the homogeneous line width of the single-dot PL spectrum. An alternative interpretation of the broad single-dot spectra observed in a material of a similar origin was put forward by Sychugov et al.,\(^{26}\) who argued that the phonon mode energies are strongly broadened in the soft-organic-shell-capped Si-NPs with respect to the hard-oxide-shell-coated Si-NPs. As a result, the breathing mode of the strong lowest-order NP splits into several directional modes, with further broadening arising from shape irregularities and strong size dependence of the acoustic phonon modes. However, we believe that a possible amorphous shell presence within these Si-NPs likely leads to a similar output and is therefore an alternative interpretation of the strongly broadened single-NP PL spectra confirmed here. An additional reason for wide single-dot PL spectra can be spectral diffusion,\(^{25}\) which could introduce an additional error in the band-gap evaluation of the order of 50–100 meV. This is, however, impossible to define under the given ambient experimental conditions.

It is interesting to realize that the size of Si-NPs estimated by STEM (Figure S10) is larger than the mean size obtained for the 50 emissive Si-NPs in Figure 3b. There are three factors that need to be discussed. First, in ambient condition AFM measurements, the omnipresent water thin film causes strong attractive capillary forces onto the tip,\(^{35}\) which shifts the oscillation frequency of the tip. These capillary forces are reduced above the NP, which in the end makes the NP appear smaller than it really is.\(^{45}\) Second, one might expect that the ligand contributes to the height, since the extended dodecene ligand contributes to the height, since the extended dodecene molecule is ∼1.67 nm long,\(^{46}\) but this is in fact a negligible effect,\(^{45,47}\) owing to the strong surface lateral capillary forces and low degree of surface coverage by the alkyl chains limited.
by steric hindrance. Third, and most importantly, it needs to be noted that the AFM histogram in Figure 3b does not represent the Si-NP ensemble, like the STEM size evaluation, but only the 50 Si-NPs that were selected through the single-NP PL spectroscopy. This is only a small subset of the Si-NP ensemble. Single-dot spectroscopy is known to be systematically biased toward the brighter and hence smaller Si-NPs, owing to their size-dependent radiative rate. To compare the PL of the analyzed subset of the 50 Si-NPs with the Si-NP ensemble, we sum up all of the single-NP PL spectra and compare the result with the NP ensemble PL spectrum, excited and measured under the same experimental conditions (Figure 3c). We find a blue shift in the summed-up single-NP PL spectrum, with respect to the ensemble PL spectrum, which agrees with the shift of the size histogram toward smaller Si-NPs.

The stronger contribution of the smaller Si-NPs can be quantitatively analyzed by measurement of the spectrally resolved PL lifetime. In Figure 5a, we show spectrally resolved average PL lifetimes $\langle \tau \rangle$ measured under a picosecond-pulsed excitation at 445 nm and plotted against the PL ensemble spectrum. The spectral resolution is achieved by the use of narrow (40 nm bandwidth) band-pass filters in the detection chain. The as measured time-resolved PL signal $I(t)$ is shown in Figure 5b, fitted by a stretched exponential function $I(t) \propto \exp \left[-(t/\tau_0)^\beta \right]$ and yielding an average lifetime $\langle \tau \rangle = (\tau_0/\beta)^{-1} \Gamma(1/\beta)$, depicted in Figure 5a (red circles). The ensemble results without spectral filtering are shown for comparison in Figure S6. As expected, the average PL lifetimes show a strong spectral dependence, as a result of size-effect in indirect band-gap Si-NPs. In particular, we found the average PL lifetime within the spectral band of 600 ± 20 nm to be 9.1 μs, increasing gradually up to 192 μs for the 850 ± 20 nm spectral window, suggesting that the smaller Si-NP would appear approximately 20 times brighter than the larger Si-NP, assuming that they are subjected to the same nonradiative channels. Smaller Si-NPs are therefore more visible in the single-NP PL spectroscopy used for selecting the Si-NPs for our correlative study.

The notion that emission is likely dominated by the amorphous parts of the Si-NP structure might be surprising because these Si-NPs were annealed up to 1300 °C, which is usually considered high enough to induce full crystallization. However, recent research by several groups indicates that the assumption of full crystallization upon high-temperature annealing might be flawed. First, experimental results by Thiessen et al., which put forward an opposing interpretation of the PL from such crystalline core–amorphous shell Si-NP systems. In their study, the authors measure an average Si-NP size using XRD and transmission electron microscopy (TEM) and ensemble optical properties, showing that Si-NP batches with the same mean outer size, but with various crystallinities, show very different PL spectra and lifetimes. It is argued that such results indicate that it is the crystalline core, and not the amorphous shell, that dominates the optical properties. However, we would like to note that ref 17 only offers an indirect correlation between the optical band gap and size and that the authors choose to fit the size dependence of both samples with a fixed bulk band-gap value, the crystalline Si one, instead of fitting the band gap to their data. Hence, we see controversy only in the interpretation and data analysis and not in the data itself, which should be further scrutinized.

**CONCLUSIONS**

In summary, we show a direct measurement of the size dependence of the band gap in the Si-NP system that has been previously reported to contain a crystalline core and an amorphous shell, with the core dominating the PL. The measured size-dependent PL band gap is fitted using the Brus equation and found to better fit the amorphous bulk Si band gap than the crystalline bulk Si one. This is very interesting for several reasons.

(i) First, it is somewhat surprising that annealing at 1300 °C does not render the Si-NPs fully crystalline. It has been assumed for a long time that NPs require a temperature lower than the bulk melting temperature to melt and it was assumed that upon cooling of a fully melted Si nanodroplet, one would obtain fully crystalline Si-NPs. However, this assumption is challenged by a recent study by Talyzin et al., which suggests that molten Si nanodroplets do not return to the crystalline form but remain fully amorphous and that Si-NP surface has a melting temperature different from that of its core. The phase-equilibrium model of crystallization indicates that the melting temperature of NPs decreases relative to the bulk melting temperature (~1414 °C for Si) linearly with their reciprocal radius $T_m(R^{-1})$ though this model does not work very well for covalent materials like Si, where formation of defects (and hence also surfaces) has dynamics different from that in the simpler ionic/metallc nanosystems. This is more appropriately treated in the so-called surface-phonon instability model, accounting for the lowering energy of the phonon modes with increasing concentration of defects, offering a better fit to the experimentally observed data. These observations indicate that melting of the disordered surfaces occurs at lower temperatures compared to the melting of the crystalline core, in agreement with the aforementioned study by Talyzin et al. This could rationalize the formation of a crystalline core–amorphous shell Si-NP system.

It is important to also discuss the recent study by Thiessen et al., which puts forward an opposing interpretation of the PL from such crystalline core–amorphous shell Si-NP systems. In their study, the authors measure an average Si-NP size using XRD and transmission electron microscopy (TEM) and ensemble optical properties, showing that Si-NP batches with the same mean outer size, but with various crystallinities, show very different PL spectra and lifetimes. It is argued that such results indicate that it is the crystalline core, and not the amorphous shell, that dominates the optical properties. However, we would like to note that ref 17 only offers an indirect correlation between the optical band gap and size and that the authors choose to fit the size dependence of both samples with a fixed bulk band-gap value, the crystalline Si one, instead of fitting the band gap to their data. Hence, we see controversy only in the interpretation and data analysis and not in the data itself, which should be further scrutinized.

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(ii) Second, another study on a similar material by Thiessen et al.\textsuperscript{17} arrived at an opposite interpretation that the PL is dominated by the crystalline Si core. However, their analysis is only indirect, and data were fitted assuming convergence to a bulk Si band gap. Therefore, we suggest that there is a critical need for direct size-dependence band-gap measurements by correlative single-dot methods, as performed here. Also, we suggest that the band gap of the material should not be assumed but fitted.

(iii) Third, sol–gel synthesis has so far resulted in the most promising emission efficiencies with a high QY of 40\% in the red spectral range for oxide-free Si-NPs.\textsuperscript{19} This synthesis is easily scalable and hence interesting for industrial applications. However, unlike most organically capped Si-NPs, this material exhibits a slow PL lifetime, very broad single-dot PL spectra, and a red-shifted PL with a weak size dependence, typically attributed to oxide-capped Si-NPs. In our study, we confirm that this material is not oxidized and contains both crystalline and amorphous Si. However, it seems that the amorphous shell dominates the PL and hence leads to a weaker size dependence of the band gap. Hence, we would like to suggest that an often observed weak size dependence of the optical band gap in Si-NPs in the literature might also be attributed to the presence of the disordered phase.

\section*{METHODS}

Synthesis of Si-NPs was carried out by the group of Veinot and is described in detail elsewhere.\textsuperscript{18} In brief, Si-NPs were prepared from hydrogen silsesquioxane (HSQ), annealed in an atmosphere of 5\% hydrogen (H\textsubscript{2}) and 95\% argon (Ar) for 1 h at 1300 °C. The process leads to stoichiometric silica SiO\textsubscript{2}, which after annealing forms Si-NPs inside a stoichiometric silica (SiO\textsubscript{2}) powder. To release the Si-NPs, the powder is dispersed in a solution of hydrogen fluoride (HF) and deionized water with a ratio of 1:1. Then, the Si-NPs are dissolved in toluene and 1-dodecene mixtures, where 1-dodecene encapsulates the Si-NP by photochemical hydroisolation, initialzed under 365 nm UV illumination. Afterward, centrifugation is used to separate the Si-NPs from the solvent, and Si-NPs are dispersed in toluene. The schematic sketch of the synthesis and the final Si-NP is shown in Figure 1.

For the optical spectroscopy of the Si-NP ensemble, Si-NPs are kept in solution, dispersed in toluene, and placed inside quartz cuvettes (110-QS from Hellma-Analytics). For the correlative single-dot microscopy and AFM measurements, we dilute the Si-NP cuvettes (110-QS from Hellma-Analytics). For the correlative single-dot methods, as performed here. Also, we suggest that the band gap of the material should not be assumed but fitted. noise ratio is improved using long acquisition times for both the single-dot PL images and spectra.

The optical microscopy system comprises an inverted microscope (Zeiss Axio Observer Z1) where the original Zeiss mechanical sample stage is replaced by a stabilized nanoprecision tip-assisted optical scanning stage (TAO Nanowizard 3; JPK Instruments). The microscope is equipped with an oil-immersion objective (Zeiss Plan-Apochromat, 100× magnification, NA = 1.4) and a filter cube with a dichroic mirror (Semrock; 442-nm laser BrightLine) and a long-pass filter (Semrock; 458-nm EdgeBasic). Excitation is performed by a 445 nm solid-state diode laser (Becker & Hickl GmbH; BDL-445-SMN) operating either in a continuous wave (cw) mode (maximum average power of 7.40 mW) or a pulsed mode (9.2 ns pulses with a 1428.6 Hz repetition rate). The PL spectra were excited by a round approximate Gaussian profile excitation laser spot with a radius of ∼40 μm and an average power of 6.28 mW; hence, the excitation density is estimated to be ∼130 W/cm\textsuperscript{2}. To detect spectrally resolved PL spectra of single NPs, we use a spectrometer (Acton SP2300; Princeton Instruments; grating with 300 grooves/mm, blazed at 750 nm) coupled to a Si-based liquid nitrogen (LN)-cooled charge-coupled-device (CCD) detector (Pylon 400B) array with 1340 × 400 pixels and a pixel size of 20 × 20 μm\textsuperscript{2}. To measure the PL lifetime, we use an avalanche photodiode (APD; ID-Quantique; ID100-50), coupled to a time-correlated single-photon counting (TCSPC) card (Becker & Hickl GmbH; DPC-230). The atomic force microscope head is placed on top of the TAO stage and is operated in tapping (AC) mode. For scanning, we use Si-based Al-coated tips (NanoWorld NCHR-10 PointProbe) with ∼15 nm radius. The ideal lateral and vertical resolution of this system is ∼30 and 0.1 nm, respectively. The measured particles appear much broader in lateral dimensions than they are in reality because their lateral size and shape are given by the convolution of the tip size and shape and the particle's size and shape. Therefore, for convenience, the lateral data are not used or interpreted. The size of the scanning area is 20 × 20 μm\textsuperscript{2}, which is divided into 2048 × 2048 steps in-plane and measured with a slow 0.5 Hz scanning rate. The alignment protocol is described in detail in the Supporting Information.

The measurement protocol for the correlated AFM and optical microscopy is illustrated in Figure 2b,c. First, we construct the overall AFM images of the optical field of view (FOV) by stitching separate AFM scan patches. The correlation between the PL image and the AFM scan is done optically using the coarse alignment described in the previous paragraph. For the spectral resolution, a slit of 2 μm width is introduced into the focal plane. The projection of the slit can be visualized in the PL image for precise control. This allows us to measure spectra of the Si-NPs falling into the slit at once. To cover the whole PL image, the slit is effectively scanned over the sample, which in practice is realized using the sample TAO stage with an accuracy of 0.1 μm/step. To increase the photon counts, we bin the spectral signal by 8 pixels on the spectral axis, which is possible due to the broad spectral feature observed at room temperature. Also, we use spatial binning by 2 pixels. PL spectra are acquired for 6 min. Subsequently, the background signal is removed by subtracting the signal from the neighboring (binned) pixels. The acquired PL emission rate of a typical single Si-NP after subtracting the background is typically above 10 counts/s in a spectral bin. Finally, all spectra are corrected for the spectral response of the detection chain by use of a calibrated black-body-radiation source (tungsten halogen lamp and deuterium lamp). The correction curve (in the form of a multiplication correction factor) is shown in Figure S7. Spectra are fitted on the energy scale (after multiplying the intensity by the square of the wavelength to correct for nonlinear conversion between wavelength and energy) by a single Gaussian function (assuming inhomogeneous line broadening). Thanks to the direct correlation between the optical image and AFM, we can then correlate the size evaluated from the height of the NPs in the AFM scan and the optical band-gap energy, obtained from the Gaussian fit of the same single-dot PL spectrum as the peak energy.

Ensemble samples were also analyzed using standard UV–vis spectroscopy. Extinction spectra were measured using a standard
spectrophotometer (PerkinElmer; Lambda 950) equipped with deuterium and tungsten halogen excitation lamps and a photomultiplier tube (PMT) detector, sensitive in the spectral range of 250–860 nm (1.442–4.959 eV). The system is equipped with a dual-stage, which allowed us to simultaneously measure the sample and the reference. PL excitation (PLE) spectra of the ensemble were measured using a spectrofluorometer (Fluorolog-3; Horiba Scientific) equipped with a 450 W excitation xenon lamp (Ushio) and a Si-based CCD detector (Synapse; Horiba Scientific) in the VIS spectral range. Samples were excited between 300 (4.133 eV) and 500 nm (2.480 eV) with a resolution of 5 nm. All spectra were corrected for the spectral response of the detection system.

Samples were further analyzed by STEM (FEI Verios 460), micro-Raman spectroscopy (Witec-alpha 300 Raman system; UHT S3005 VIS spectroscopy, 532.3 nm excitation, Zeiss EC Epiplan-Neofluar 100x objective with a numerical aperture of 0.9), and 2Θ XRD spectrometry from 10 to 90° with a 0.5°/min scanning rate (Rigaku; MiniFlex-II).

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/acsanm.0c02395.

Description of the setup methodology of the correlative optical microspectroscopy and AFM; additional spectrometry data (extinction, PL and PLE spectra of the sample, analysis of the Tauc plot for absorption of the sample; PLE map for a broad range of PL energies; single-dot PL spectra fitted by a Gaussian peak function; histogram of single-dot PL spectra FWHM; time-dependent PL signal; and PL correction curve); and size estimation (topography of an empty substrate; size histogram of the Si-NPs obtained from STEM; and additional Raman spectra for Si-NP clusters) (PDF)

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Author Contributions

C.-C.H. performed most of the measurements and data analysis. K.D. conceived and supervised the project. Y.T. provided XRD spectra and NP size statistics from STEM images. M.v.d.L. provided micro-Raman spectroscopy data on the setup facilitated by J.v.d.G. All authors provided feedback and contributed to the manuscript.

Notes

The authors declare no competing financial interest.

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